Notice of References Cited

Ī	Application/Control No.	Applicant(s)/Pater	nt Under
	10/536,909	Reexamination YASUDA ET AL.	
	Examiner	Art Unit	
	Amanda C. Walke	1795	Page 1 of 1

II S PATENT DOCUMENTS

				U.S. PATENT DOCUMENTS	
*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	Α	US-2007/0212556	09-2007	Musa et al.	428/447
*	В	US-5,998,089	12-1999	Tajima et al.	430/270.1
*	С	US-6,380,434	04-2002	Chiang, Long Y.	564/458
*	D	US-2004/0265731	12-2004	Okada et al.	430/270.1
*	Е	US-6,844,429	01-2005	Mikata et al.	536/1.11
	F	US-			
	G	US-		-	
	Н	US-		-	
	Т	US-			
	J	US-			
	К	US-			
	L	US-			
	м	US-			

FOREIGN PATENT DOCUMENTS

	FOREIGN FATENT DOCUMENTS					
*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N	WO 9626186 A1	08-1996	World Intellect	MATTAY et al.	
	0					
	Р					
	Q					
	R					
	s					
	Т					

NON-PATENT DOCUMENTS

		NON-FATENT DOCUMENTS				
*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)				
	U	Bellavia-Lund et al, Phosphous, Sulfur, and Silicon, VOI. 120&121, pp. 107-119 (1997).				
	v					
	w					
	×					

A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)

Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.